

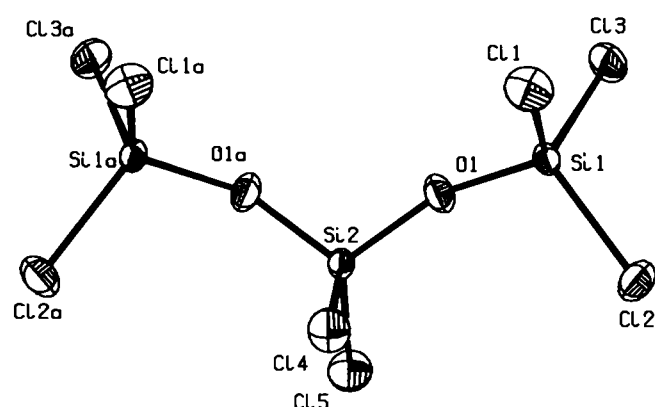
# Crystal structure of catena-octachlorotrisiloxane, $\text{Si}_3\text{O}_2\text{Cl}_8$

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**Table 1.** Data collection and handling.

Crystal:	colourless needle, size 0.2 × 0.2 × 1.0 mm
Wavelength:	Ag $K\alpha$ radiation (0.56086 Å)
$\mu$ :	9.65 cm <sup>-1</sup>
Diffractometer, scan mode:	Syntex P2 <sub>1</sub> , $\omega$
$2\theta_{\text{max}}$ :	52.14°
$N(hkl)_{\text{measured}}$ , $N(hkl)_{\text{unique}}$ :	5622, 2769
Criterion for $I_{\text{obs}}$ , $N(hkl)_{\text{gt}}$ :	$I_{\text{obs}} > 2\sigma(I_{\text{obs}})$ , 2266
$N(\text{param})_{\text{refined}}$ :	64
Programs:	SHELXS-86 [2], SHELXL-93 [3], PLATON [4]

## Abstract

$\text{Cl}_8\text{O}_2\text{Si}_3$ , orthorhombic,  $Pnma$  (No. 62),  $a = 10.669(1)$  Å,  $b = 20.317(3)$  Å,  $c = 6.183(1)$  Å,  $V = 1340.4$  Å<sup>3</sup>,  $Z = 4$ ,  $R_{\text{gt}}(F) = 0.023$ ,  $wR_{\text{obs}}(F^2) = 0.055$ ,  $T = 90$  K.

## Source of material

The preparation method for chlorosiloxanes  $\text{Si}_x\text{O}_y\text{Cl}_z$  is described in the literature [1].  $\text{Si}_3\text{O}_2\text{Cl}_8$  can be isolated and purified by fractional distillation. The compound is highly moisture sensitive.

## Discussion

High temperature reaction between siliconchloride ( $\text{SiCl}_4$ ) and oxygen leads to  $\text{SiO}_2$ . At about 1300 K chlorosiloxanes like  $\text{Si}_3\text{O}_2\text{Cl}_8$  are formed as intermediates during this reaction. The molecular structure of these compounds are of particular interest regarding the pathway from molecular  $\text{SiCl}_4$  to solid  $\text{SiO}_2$ .  $\text{Si}_3\text{O}_2\text{Cl}_8$  shows the expected chain structure with bridging oxygen atoms.

## References

1. Quellhorst, H.; Wilkening, A.; Binnewies, M.: Trennung und massenspektrometrische Charakterisierung von Perchlorsiloxanen. *Z. Anorg. Allg. Chem.* **623** (1997) 1871-1874.
2. Sheldrick, G. M.: SHELXS-86. A program for crystal structure determination, University of Göttingen, Germany 1990.
3. Sheldrick, G. M.: SHELXL-93. A program for refining crystal structures, University of Göttingen, Germany 1993.
4. Spek, A. L.: PLATON, an integrated tool for the analysis of the results of a single crystal structure determination. *Acta Crystallogr. Suppl.* **A46** (1990) C-34.

**Table 2.** Atomic coordinates and displacement parameters (in Å<sup>2</sup>).

Atom	Site	x	y	z	$U_{11}$	$U_{22}$	$U_{33}$	$U_{12}$	$U_{13}$	$U_{23}$
Si(1)	8d	0.91472(3)	0.38581(1)	0.11360(4)	0.0195(1)	0.0133(1)	0.0187(1)	-0.00166(9)	-0.00075(9)	-0.00163(8)
Si(2)	4c	0.79252(3)	1/4	0.02150(6)	0.0160(2)	0.0120(2)	0.0186(2)	0	0.0000(1)	0
Cl(1)	8d	1.07992(3)	0.38149(2)	-0.04216(5)	0.0248(1)	0.0437(2)	0.0335(1)	-0.0037(1)	0.0086(1)	-0.0005(1)
Cl(2)	8d	0.79685(3)	0.44556(2)	-0.04713(5)	0.0414(2)	0.0256(1)	0.0314(1)	0.0109(1)	-0.0096(1)	0.0010(1)
Cl(3)	8d	0.94030(3)	0.41963(2)	0.41488(4)	0.0367(1)	0.0267(1)	0.0221(1)	-0.0011(1)	-0.0049(1)	-0.00781(9)
Cl(4)	4c	0.81927(4)	1/4	-0.30012(6)	0.0388(2)	0.0321(2)	0.0189(2)	0	0.0026(1)	0
Cl(5)	4c	0.60814(4)	1/4	0.08485(8)	0.0170(1)	0.0348(2)	0.0437(2)	0	0.0054(1)	0
O(1)	8d	0.85557(8)	0.31359(4)	0.1295(1)	0.0306(4)	0.0160(3)	0.0272(3)	-0.0063(3)	-0.0028(3)	-0.0011(3)

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